



ISPlasma2021 / IC-PLANTS2021

13th Anniversary International Symposium on Advanced Plasma Science
and its Applications for Nitrides and Nanomaterials /
14th International Conference on Plasma-Nano Technology & Science
Virtual Symposium March 7-11, 2021

Best Presentation Award

in the area of Plasma Science

to


**THI-THUY-NGA NGUYEN, MINORU SASAKI,
TAKAYOSHI TSUTSUMI, KENJI ISHIKAWA
AND MASARU HORI**

“Design of Removal Process of SnO₂ on Glass by
H₂/Ar Plasma at Atmospheric Pressure and
Medium Pressure”



Masafumi Ito

Chairperson of ISPlasma2021 / IC-PLANTS2021 Organizing Committee
Professor of Meiji University



Kenji Ishikawa

Chairperson of ISPlasma2021 / IC-PLANTS2021 Program Committee
Professor of Nagoya University